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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/678,301	10/06/2003	Hiroo Takizawa	Q77851	4148
65565 SUGHRUE-26	7590 12/22/2006 5550		EXAMINER  ANGEBRANNDT, MARTIN J  ART UNIT PAPER NUMBER	
2100 PENNSY	LVANIA AVE. NW			
WASHINGTO	N, DC 20037-3213			
			1756	
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SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MO	NTHS	12/22/2006	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

	Application No.	Applicant(s)	
Office Author Occurs	10/678,301	TAKIZAWA ET AL.	
Office Action Summary	Examiner	Art Unit	
	Martin J. Angebranndt	1756	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period was precised to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	lely filed the mailing date of this communication. (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 10/13	3/06 & 11/9/06.		
	action is non-final.		
3) Since this application is in condition for allower		secution as to the merits is	
closed in accordance with the practice under E	•		
Disposition of Claims			
4) Claim(s) 16 is/are pending in the application.			
4a) Of the above claim(s) is/are withdraw	vn from consideration.	·	
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>16</u> is/are rejected.			
7) Claim(s) is/are objected to.		•	
8) Claim(s) are subject to restriction and/or	election requirement.	•	
Application Papers			
9) The specification is objected to by the Examiner	r <b>.</b>		
10) The drawing(s) filed on is/are: a) acce	epted or b) objected to by the E	Examiner.	
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	37 CFR 1.85(a).	
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).	
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:	priority under 35 U.S.C. § 119(a)	-(d) or (f).	
1.☐ Certified copies of the priority documents	s have been received		
2. Certified copies of the priority documents		on No.	
3. Copies of the certified copies of the prior			
application from the International Bureau			•
* See the attached detailed Office action for a list of	` ''	d.	
	·		
Attachment(s)			
1) Notice of References Cited (PTO-892)	4) Interview Summary		
Notice of Draftsperson's Patent Drawing Review (PTO-948)   Information Disclosure Statement(s) (PTO/SB/08)	Paper No(s)/Mail Da 5) Notice of Informal Pa		
Paper No(s)/Mail Date	6) Other:	•••	

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1. The response of the applicant has been read and given careful consideration. The proper terminal disclaimers are sufficient to obviate the double patenting rejections. The amendment to the claims obviates the previous rejections.

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- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Farid et al. '529, in view of Harada et al. '032 and Swainson et al. '861

Farid et al. '529 forms a composition comprising dye PS-31 (col 23-24), a binder, monomer and inhibitor and an activator, exposed to light and the number of steps hardened determined. (see also 16/27-18/19). The dye PS-31 has a absorption maximum of 453 nm.

Other sensitizers used include the cyanine dyes of table 1 (PS-1 through PS-12), styryl dyes PS-13 through PS-20 and xanthene dyes PS-32 to PS-33. The use of various substrates including aluminum and lithographic paper is disclosed. (14/17-36). The use of oxonol dyes is disclosed merocyanine, hemioxonol, cyanine, hemicyanine and styryl dyes. (4/27-44)

Harada et al. '032 teach the curing of photopolymerizable compositions using two photon processes. The light is an ultrashort pulses from a Ti:Sapphire. [0013]. The two photons absorbed add up to the energy of a photon of half their wavelength and curing takes place only where the focus occurs resulting in high resolution capability and fewer problems. [0016-0019].

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The Ti:Sapphire emits a pulse of 100-300 fs pulse at a wavelength within the 700-900 nm range. [0044-0045].

Swainson et al. '861 establish that the use of two photon processes is old and well known in the imaging arts. In the embodiments of Class I, Group 2, a two photons of the same wavelength are used to cause the photoreaction. The energy difference between the two states being greater than the energy of a single photon, but equal or less than twice the energy of the photon. The starting point is a material with known one photon photoresponsive properties.

Example 3 is a photopolymerization system including xanthene dye sensitizer eosin Y. (5/30-6/35). The two photon sensitivity of cyanine dyes is disclosed. (12/48-51).

It would have been obvious to one skilled in the art to modify the process of Farid et al. '529 in the examples using dye PS-31 by using a two photon exposure process with a Ti:Sapphire laser tuned to a wavelength of 900 nm which is near the two photon absorption of maxima of ~ 906 nm as taught by Harada et al. '032 to increase the resolution of the imaging process as discussed by Harada et al. '032 with a reasonable expectation of exciting the two photon polymerization based upon the teachings of Swainson et al. '861 showing this for cyanine and xanthene dyes and establishing that a good starting point is a compound having a single photon response, which is established for the oxonol dye PS-31 by Farid et al. '529.

4. Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Farid et al. '529, in view of Harada et al. '032 and Swainson et al. '861, further in view of Penzkofer et al., "So and S<sub>1</sub> two photon absorption dynamics of organic dyes solutions", Opt. Quantum electron. Vol. 19 pp. 327-349 (1987)

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Penzkofer et al., "So and S1 two photon absorption dynamics of organic dyes solutions", Opt. Quantum electron. Vol. 19 pp. 327-349 (1987) teaches the two photon absorption of trimethine dye HMICI and PYC, with PYC bearing ketone containing terminal moieties similar to those of an oxanol dye.

In addition to the basis provided above, the examiner cites Penzkofer et al., "So and S1 two photon absorption dynamics of organic dyes solutions", Opt. Quantum electron. Vol. 19 pp. 327-349 (1987) to futher support the position that the oxonol dye PS-31 will have an appreciable two photon absorption cross section, sufficient to cause two photon polymerization, further supporting the obviousness of the combination of Farid et al. '529, in view of Harada et al. '032 and Swainson et al. '861 set forth above.

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Tsien et al. '379 teaches the single photon absorption of a trimethine oxonol dye as being 542 nm (16/1-17), so the two photon absorption would be at 1084 nm. The use of two photon processes is disclosed. (2/50)

6. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37

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CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J. Angebranndt whose telephone number is 571-272-1378. The examiner can normally be reached on Monday-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

> Martin J Angebranndt Primary Examiner

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